Objective lenses

Parfocal distance 60mm

Objective lens	W.D.(mm)	NA
$5 \times$	23.50	0.15
10 ×	17.50	0.30
$20 \times$	4.50	0.45
50× Apo	2.00	0.80
100× Apo	2.00	0.90
150× Apo	1.50	0.90
Objective lens (long working distance)	W.D.(mm)	NA
$20 \times ELWD$	19.00	0.40
$50 \times ELWD$	11.00	0.60
100× ELWD	4.50	0.80
Objective lens (super long working distance)	W.D.(mm)	NA
10× SLWD	37.00	0.20
20× SLWD	30.00	0.30
50× SLWD	22.00	0.40
100× SLWD	10.00	0.60
Objective lens (glass thickness correction)	W.D.(mm)	NA
$20 \times LCD$	10.00	0.45
50× LCD	3.00	0.70
100× LCD	0.85/0.95	0.85

Parfocal distance 45mm

Objective lens (high NA)	W.D.(mm)	NA
50× Apo	0.35	0.95
100 × Apo	0.32	0.95
Special objective lens (high NA)	W.D.(mm)	NA
$5 \times LT$	10.50	0.25
10× LT	1.60	0.50
20× LT	0.70	0.75

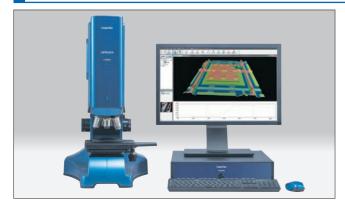
CFI60 series

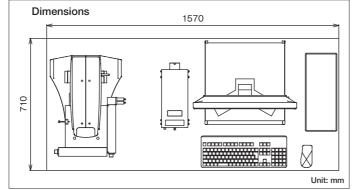


Special objective lens (high NA)



Dimensions, Exterior







Lasertec HQ was certified ISO9001:2008 in June 2009.



Safety precautions: Read manuals before use. Use properly.

- This catalog provides information as of January 2015.
 The descriptions in this catalog are based on our research as of the product release.
- Product specifications are subject to change without notice. Neither manufacturer nor seller assumes any responsibility for damage caused by specification change.
 Screen images are simulated.

Lasertec Corporation

Head Office Solution Sales Department II	2-10-1 Shin-yokohama, Kohoku-ku, Yokohama 222-8552 Japan Phone +81-45-478-7330		
Subsidiaries outside Japan	U.S. Phone +1-408-437-1441 Korea Phone +82-31-8015-0540 Taiwan Phone +886-3-657-9120		
Homepage	http://www.Lasertec.co.jp/		
E-mail	Sales@Lasertec.co.jp		



Lasertec **OPTELICS** HYBRID

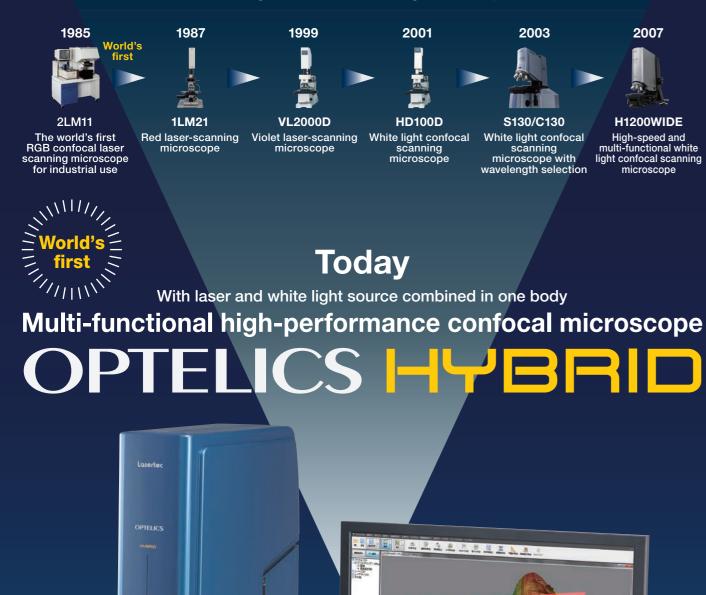


HYBRID LASER MICROSCOPE **OPTELICS** HYBRID

Optical technology at its best! Performance surpassing laser-scanning microscopes

In 1985, Lasertec released the world's first industrial-quality **RGB** confocal laser-scanning microscope

Lasertec then released red laser and violet laser microscopes and, in 2001, white light confocal scanning microscopes



Multi-functional and high-performance HYBRID

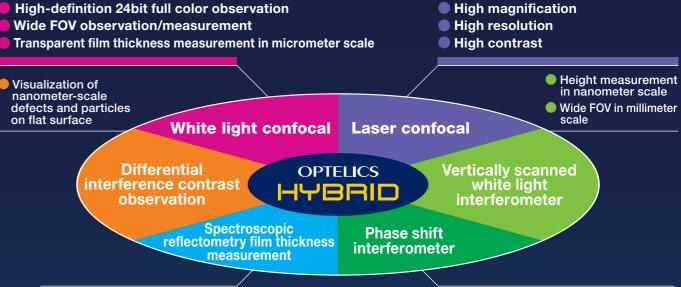
White light confocal

White light confocal and laser confocal

🗏 6 functions in one body 🗏

Featuring two sets of confocal optics combined with additional functions including interferometer, differential interference contrast observation, and spectroscopic reflectometry film thickness measurement, HYBRID performs multiple tasks that normally require several different tools.

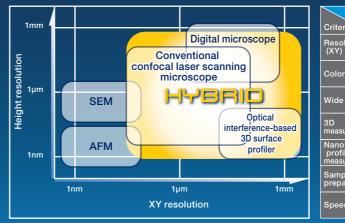
- High-definition 24bit full color observation



Film thickness measurement in nanometer scale

Faster, wider and more accurate

Wide coverage and highly accurate measurement One-stop solution





Height measurement in Angstrom scale

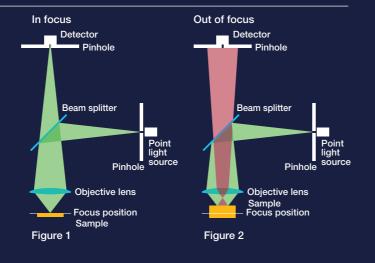
'ool	Interferometer surface profiler	Typical CLSM	SEM	Contact-type roughness gauge	AFM	HYBRID
on	((3)	3	(\odot	\odot
age		(×	—	×	3
V	(2)	(((2)	×	3
ment	3	3	((3	3
ale: ment	3	(×	(2)	3	3
tion	(2)	3		3	3	3
	3	((×	\odot

Confocal optics - basic principle of technology

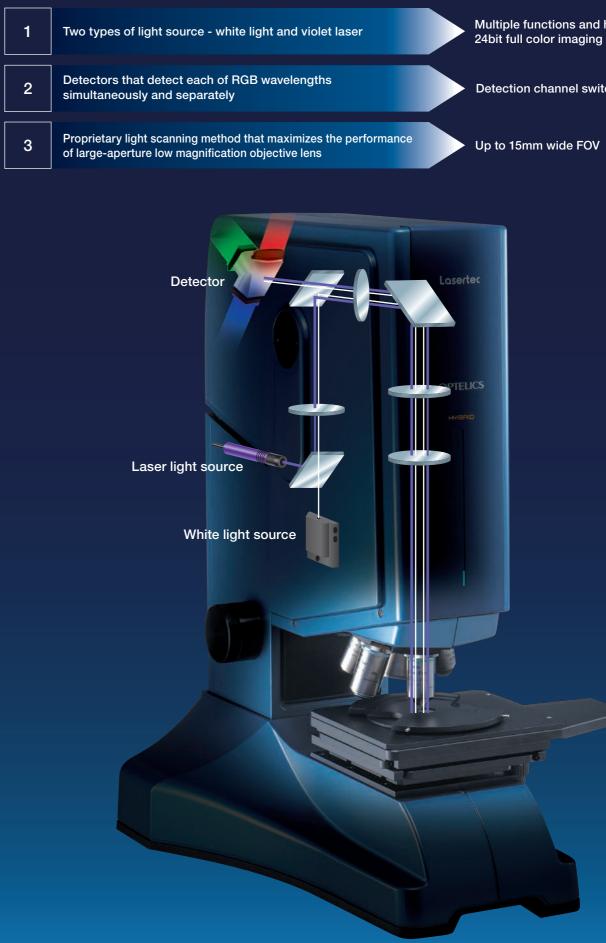
Unique confocal optics of HYBRID

Basic principle

Confocal optics detects only the rays of light focused on the sample surface. Light emitted from the source and reflected by the sample surface reaches the detector only if it is focused at the pinhole in front of it (Figure1). This takes place only for the rays of light focused at the sample surface. The light rays from the sample surface in focal plane reach the detector but all others do not (Figure2). Confocal optics detects in-focus information only.



Unique confocal optics of HYBRID

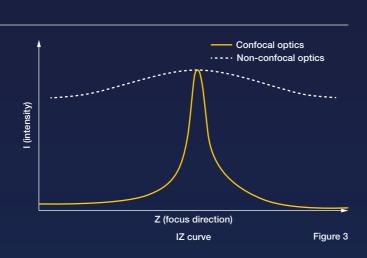


Merits of confocal optics

1. High resolution

- 2. High-contrast high-definition images without scattered light interference (Figure3)
- 3. Optical sectioning effect (see below)

These merits enable HYBRID to provide highly accurate measurement in x, y and z directions.



Optical sectioning effect

HYBRID continuously captures in-focus images of a sample being moved in z direction by taking advantage of the confocal optics principle that reflected light has its maximum brightness when it is in focus (Figure 4).

(Effect1)

By recording maximum brightness at each pixel, all-focused images can be captured (Figure 5).

(Effect2)

By recording the z position of each pixel at its peak brightness, 3D measurement such as shape and surface roughness measurement is possible (Figure6).



Multiple functions and high-definition

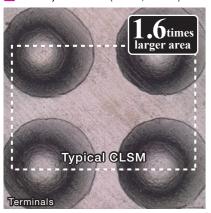
Detection channel switching function

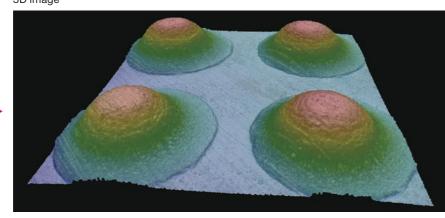
OPTELICS HYBRID means

White light confocal

Wide FOV for efficient observation

FOV 1.6 times wider than a typical CLSM % When objective lens of the same magnification is used 10x objective lens (FOV 1,500um) 3D image





High precision measurement at low magnification

With the use of our special objective lens, high precision measurement at low magnification, which CLSM is hard to achieve, is made possible.

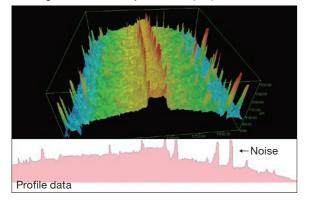
Objective lens designed especially for wide FOV and high precision measurement

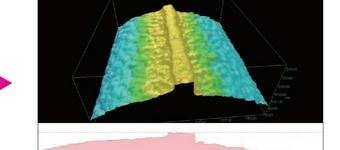
High-NA objective lens available for 5x, 10x, 20x magnification

Magnification	Normal objective lens NA	Special objective lens NA	FOV
5×	0.15	0.25	3,000×3,000µm
10×	0.30	0.50	1,500×1,500µm
20×	0.45	0.75	750×750µm

3D image from our special objective lens (10x)

3D image from normal objective lens (10x)





Wide FOV and high precision

FOV 6.5 times wider than typical CLSM is possible, thanks to HYBRID's wide FOV and the use of special high-NA low magnification objective lens.

Profile data

High-definition wide-FOV image

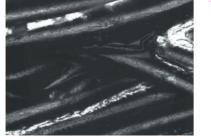
10x objective lens

(NA 0.50)

Image from typical CLSM 20x objective lens

(NA 0.46)

5



Copper wire (FOV 670µm×500µm)



(FOV 1,500µm)

High-definition images of white light confocal

With the use of Xenon lamp similar to sunlight as light source, high-definition images with good color separation and high depth of field are available.

Color image from CLSM



Black and white image from CLSM



Butterfly scales

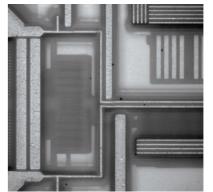
Widening applications with detector channel switching

Detector channel switching allows observation and measurement to be performed in the most suitable wavelength. It also widens your applications to samples for which laser light cannot provide a clear picture.

Different observation result of each channel

Upper layer observation: blue channel

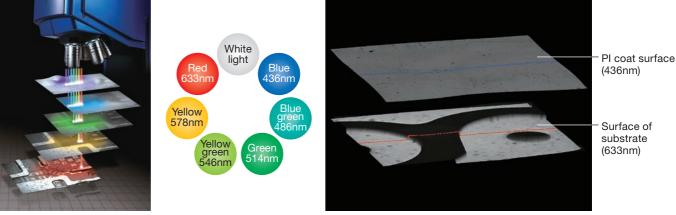




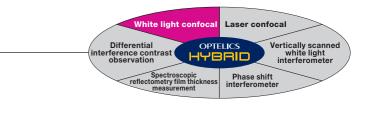
PI-coated communication device

Widening applications with light wavelength selection

The selection of 6 different wavelengths of light source is available. It allows you to select the best wavelength for your observation and measurement and widens your applications to samples susceptible to damage in a particular wavelength of light, such as resist film or UV curable resin, and samples that absorb a particular wavelength of light.



Multi layer observation using wavelength selection (concept illustration)



Color image from HYBRID

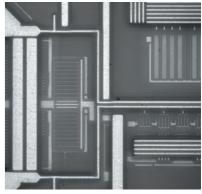


Composite image with non-confocal color image

High definition image of white light confocal

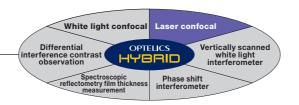
Middle layer observation: green channel

Lower layer observation: red channel



PI-coated flexible printed circuit board

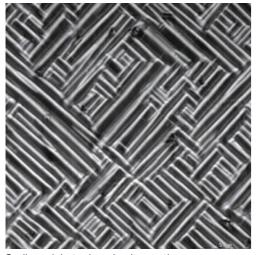
Laser confocal



High-magnification, high-resolution observation

The 405nm-laser light source allows you to capture the nanometer-scale world in an instant. Ultrafine structures can be visualized clearly.

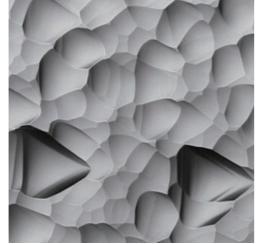
Si wafer backside



OPTELICS

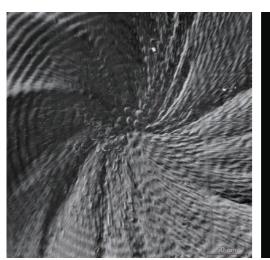
HYBRID

means

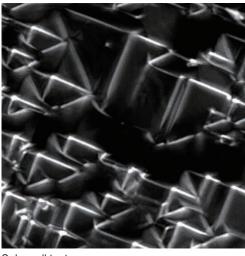


(FOV 75um, 3,700x magnification on monitor)

Sodium niobate domain observation (FOV 25um, 11,000x magnification on monitor)

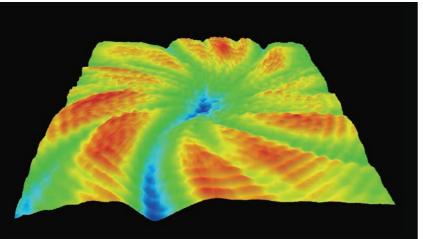


Polymer blend crystal (FÓV150um, 1,850x magnification on monitor)

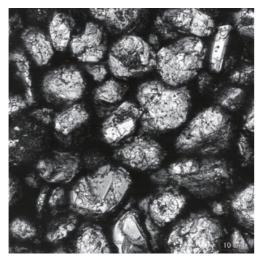


Solar cell texture (FOV50um, 5,500x magnification on monitor)

7



3D image of polymer blend crystal (FOV150um)



Active material of lithium ion battery (FOV75um, 3,700x magnification on monitor)

OPTELICS IYBRIC



High contrast visualization of nanometer-scale surface morphology based on the combination of confocal and differential interference contrast (DIC) optics.





Not clear

Epitaxial defects on S: C (FOV 1,500um) not visible





#16 565um

Not clear

Step bunching on SiC wafer (FOV 1,500um) not visible



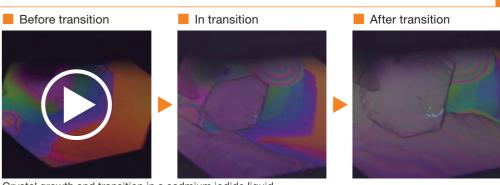
GaN epitaxial defects (FOV 1,500um) not visible

In-situ observation

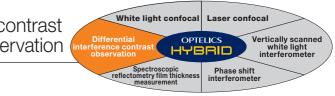
Real-time observation of liquid and other samples

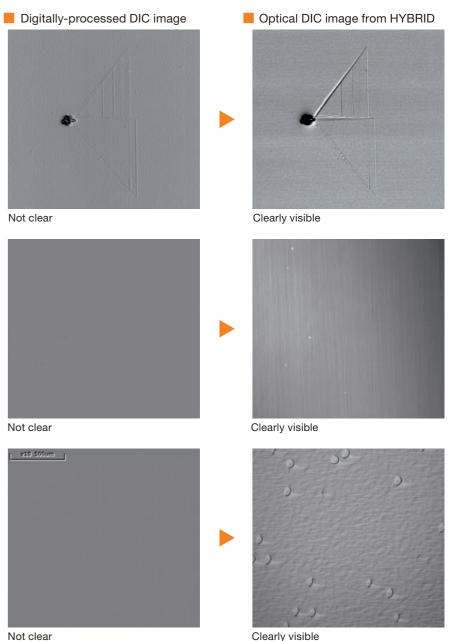
Typical usages

- Observation of phase transition of metal and inorganic samples under changing temperature conditions
- Video capture of crystal growth or phase transition in liquids



Crystal growth and transition in a cadmium iodide liquid

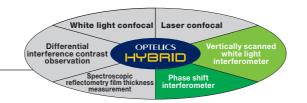




(high-definition video capture and playback at high speeds up to 15 frames per second is available)

OPTELICS

Optical interference measurement



Nanometer-scale height measurement in a wide FOV

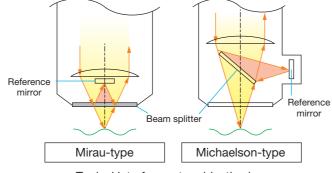
Nanometer-scale precise height measurement in a millimeter-scale FOV is possible.

Features

The resolution in height measurement using optical interference is independent from objective lens NA. It is therefore possible to have high resolution even in a wide FOV. This is suitable for measuring ultrafine concave/convex, surface roughness and unevenness while maintaining a millimeter-scale wide FOV. You can dramatically broaden a range of measurement applications by complementing this method with confocal, which is more suited to measure slopes and rough surfaces.

Basic principle of optical interference measurement

Surface profiles are measured in nanometer-scale resolution from the analysis of interference patterns generated by interference objective lens. Light is split into two arrays by a beam splitter inside the objective lens. One of the arrays is reflected by the sample surface while the other array goes to the reference mirror and reflected there. Both reflected beams are superimposed in the objective lens to form interference patterns caused by optical path differences. As the tool is adjusted to have no optical path difference in a focus position, interference fringes indicate concaves and convexes on sample surface.



Typical interferometer objective lens

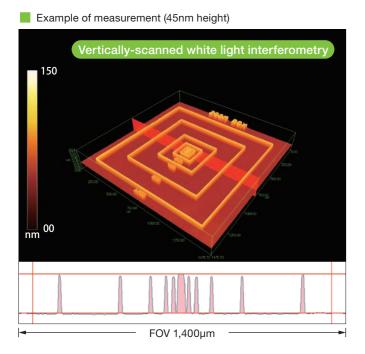
Two types of interference measurement method

Vertically-scanned white light interferometry

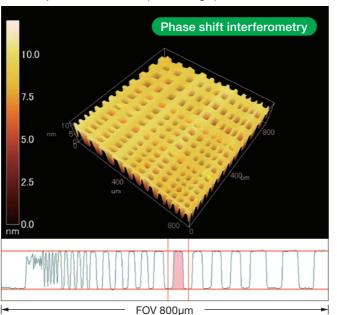
Interference fringes have the strongest contrast at in-focus plane. The peak of brightness in interference fringe is detected to measure height with the operability of confocal microscope.

Phase shift interferometry

Height measurement in Angstrom-scale accuracy is available from the phase analysis of interference fringes in a single wavelength of light (546nm) that are obtained as the phase is being changed in multiple steps. The measurement range is limited within a half wavelength but the merit is its short measurement time, which is a few seconds.



Example of measurement (8nm in height)



OPTELICS HYBRID means

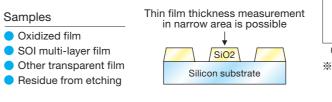
Spectroscopic reflectometry film thickness measurement

Transparent film thickness measurement

You can measure the thickness of transparent films using the capability to select 6 wavelengths in white light. Measurement area is user-settable. This function is applicable to either all surface coated films or patterned films.

Features

Spectroscopic reflectometry is available to measure transparent film thickness in nanometer scale. It compensates for the shortcoming of confocal optics, which cannot detect a focus position for a film with thickness close to the wavelength of light, thus failing to measure the thickness. HYBRID offers this spectroscopic reflectometry to broaden its applications to such a thin film measurement.



0.1nm

Principle of spectroscopic reflectometry

Spectroscopic reflectometry

Film thickness can be measured using the reflectance spectrum obtained from spectroscopic reflectometry after parameter fitting with optical simulation model.

Reflectance spectrum

It shows the relation between absolute reflectance and wavelength. It varies depending on film thicnknesses and optical constants.

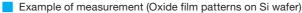
Absolute reflectance

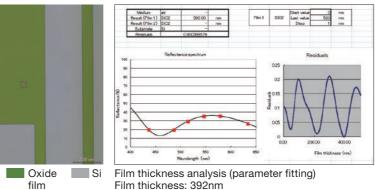
It is determined by thin film interference caused by multiple reflections of light between film surface and substrate.

Spectroscopic reflectometry of HYBRID

Six wavelengths are selected from white light to obtain a reflection image for each and to calculate reflectance.

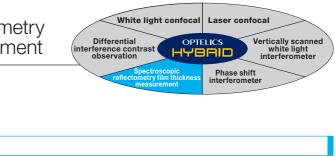
Optical constants (refractive index and extinction coefficient) for thin film and substrate are used in optical model to calculate absolute reflectance from Fresnel coefficient and to measure film thickness after parameter fitting.

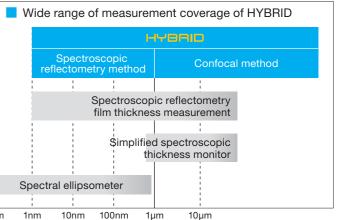




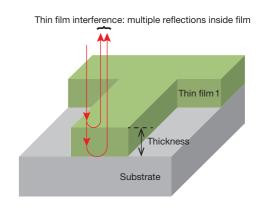
Observed film

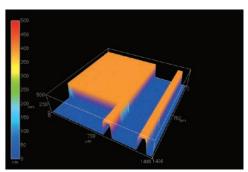
image





*Confocal's XZ cross section measurement is suitable for measuring film thicknesses more than 1um.





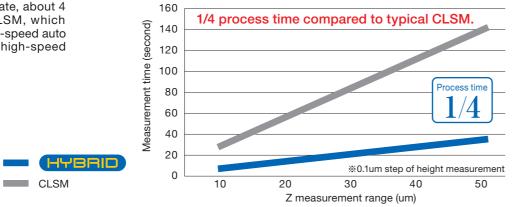
Film thickness measurement (distribution) Z scale: 500nm

High speed and high precision measurement

Industry-=____

Industry-leading measurement speed

HYBRID achieves 15Hz frame rate, about 4 times faster than a typical CLSM, which makes it a powerful tool for high-speed auto measurement, patchwork and high-speed video observation.



High speed patchwork

This function allows you to stitch a large object as the one shown on the right with ease. It creates a wide FOV image smoothly. The process time is about 1/6 of that required for a typical CLSM. (Number of screens required: 1/1.5, measurement time per screen: 1/4)

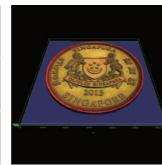




Patchwork of typical CLSM



(Diameter 22mm) *Number of shots above simulated



3D image

High-speed automatic optimization of measurement range

Process time

1/6

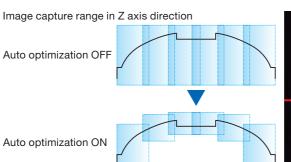
In patchwork, height gap within each FOV is automatically detected to adjust measurement range. It prevents image input errors and dramatically shortens scan time.

measurement point with one click, auto patchwork in a

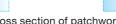
specified area on the map and

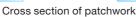
coordinate information control

in a specified position.





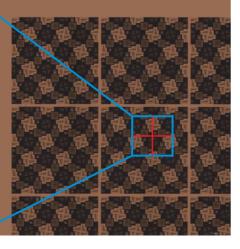






Area mapping Current measurement position can be displayed on a wider FOV image. The function also allows you to move to the





Industry-leading measurement accuracy and repeatability

High accuracy required for measurement tools

High accuracy

Line width: ±[0.02x(100 / objective)+L/1000] µm Height measurement: ±(0.11+L/100) µm Both at industry-leading level

in a short time

High level of repeatability

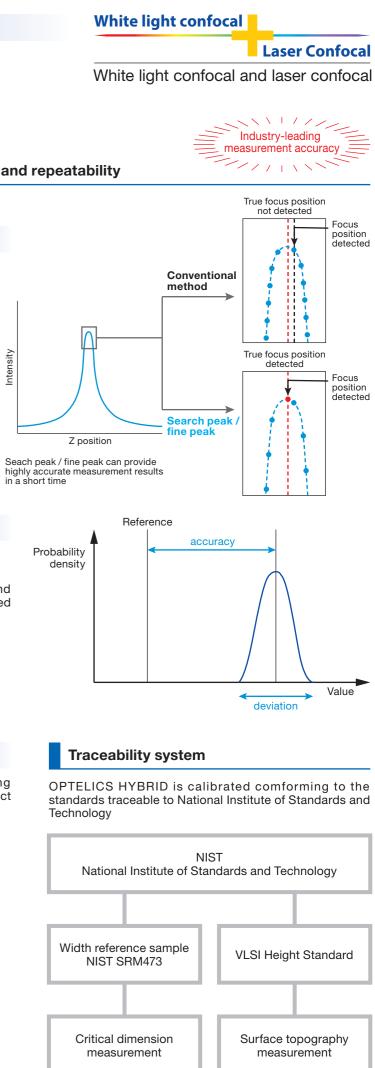
Line width measurement 3σ :10nm

Height measurement o: 10nm

HYBRID achieves an industry-leading repeatability and detects a true peak located in a measurement gap based on IZ curve calculated with a special algorithm.

Reliability

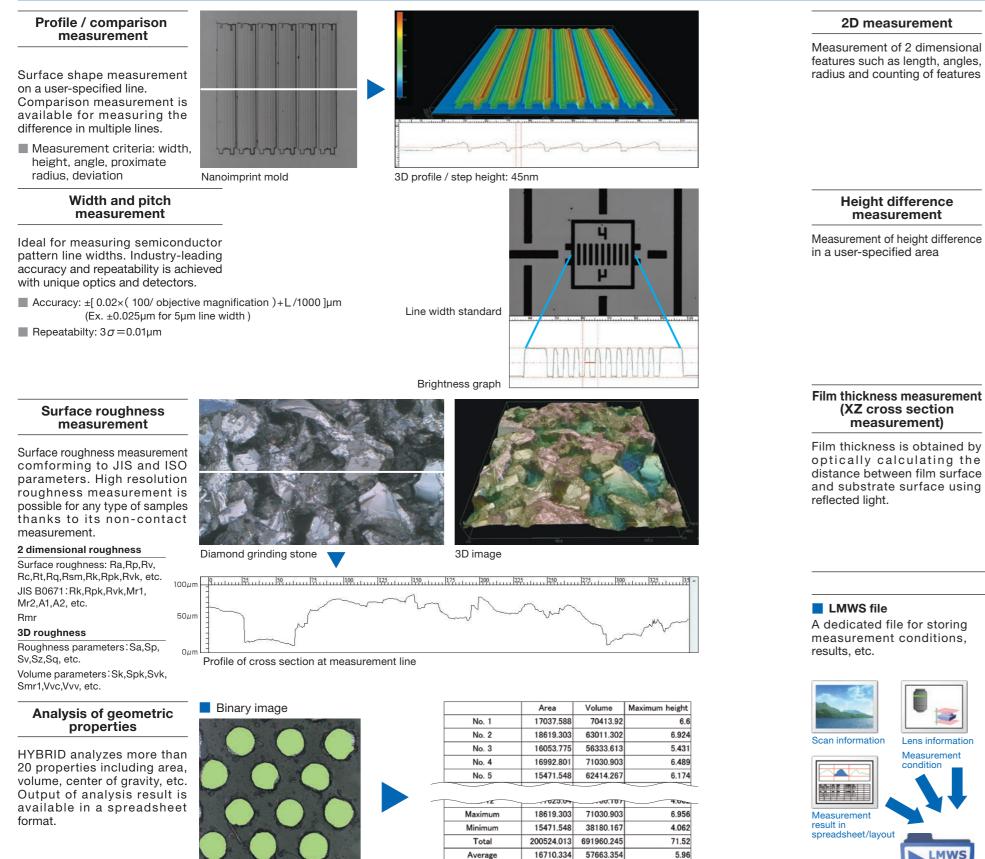
Outgoing inspection is performed on HYBRID using reference samples with correct traceability to ensure strict quality assurance.



12

Various measurement and analytical functions

Applicable to various usages



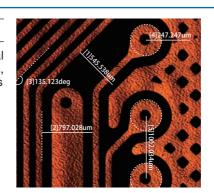
Average

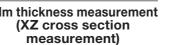
Standard deviation

Analysis result

952.076 11291.086 0.919

Bump





Film thickness is obtained by optically calculating the distance between film surface and substrate surface using

Data management

Spreadsheet

A spreadsheet for storing multiple measurement data

		- eght	تا, احد
	Fz: n a e41 (C00) 6 (C0 (C41 Gareer	0.151	30.747
	F7 mage41 (T0x) G 100 7-1 Clinter	002.	30.917
	To mage/HILC #C 1C0 IS 1 Outpoint	0.200	63747
N	FairnageAl (CCV) 9,100 (FH Gareer	0010	56747
	F7 mage41 (50x) 3 100, 10+1 Classer	0652	30.917
	2 mage/1 (btt) G 100, 11, 1 Cureon	0547	88747
	12 mage41(00%)(3)100(12+1 Cursor	3503	00047
nation	F7 mage1 (30g) 3 100, 12-1 Classer	0546	30.217
	2 mage/1/00/03/100/17/17 Cureon	0504	88.747
ent	FZ mage41(50x)[3]100[15+1 Curson	0000	00347
_	77 mage1 (30.) 3 100, 16 1 Cluson	0550	\$8.917
	[2] mage/1/00.03[107]17 [Corest	.094F	83347
	-Z mage41(50x) 3(100) 18-1 Curson	.0541	90.747
	Narimum	9658	58.507
	Mhinun	0.9.	30,917
	c 121	1 CUS	1151 RG
	5-9-10,90	3785	30347
	ிராக	0.47	3003



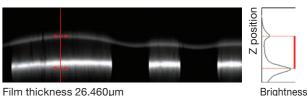
White light confocal and laser confocal

Laser Confocal



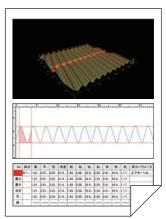






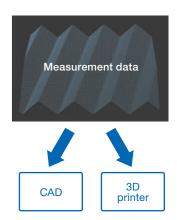
Layout report

Capability to generate reports containing images and measurement data charts



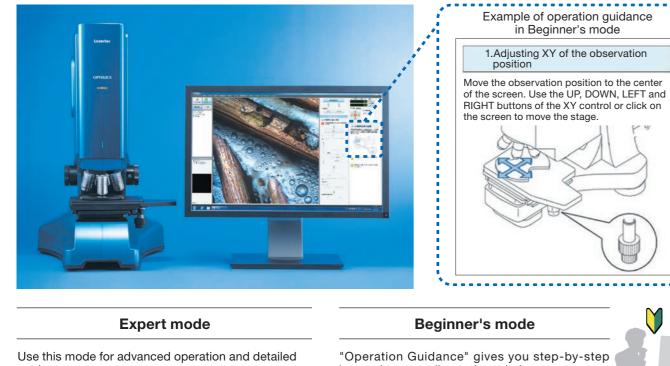
Data output

Output in image file, CSV file and CAD data (STEP file) is available



Ease of use and high skills for all users

Expert mode and Bigginner's mode



setting.

В	eg	jinner's r	no	de	_	
		0		ou step-by-step the measurement		Ł.
Sample setting		One click		Start measuring		Complete

Macro



One click on Play button does it all!

	viewer		× گ
No.	Category	Description	nata
1	Control	Light path setting	Comma
2	Control	Auto focus	Comman
3	Control	Auto scan setting	Commar
4	Control	Z scan	Comman
5	Filter	Median	Commar
6	Geometrical conversion	Horizontal correction	BaseOff
7	Measurement	Profile measurement	AddExis
8	Measurement	Roughness measurement	AddExis
1.22	File	Save (image)	Comman

Operate a measurer sequence or analysis process while saving commands in a macro.

Expert

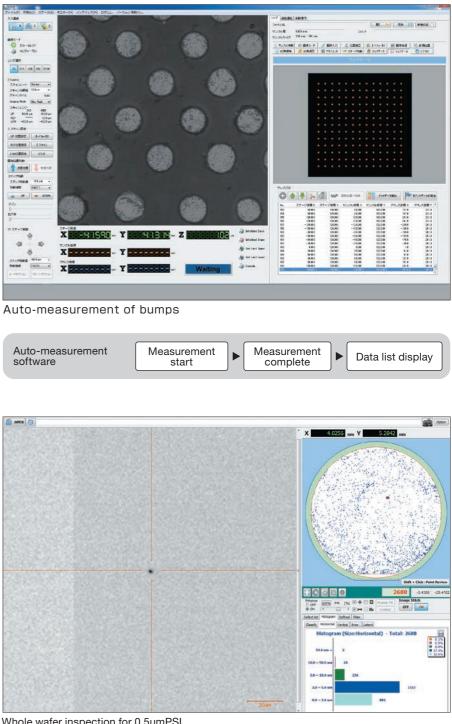


Software programs for automated operation

Auto-measurement software

OPTELICS HYBRID means

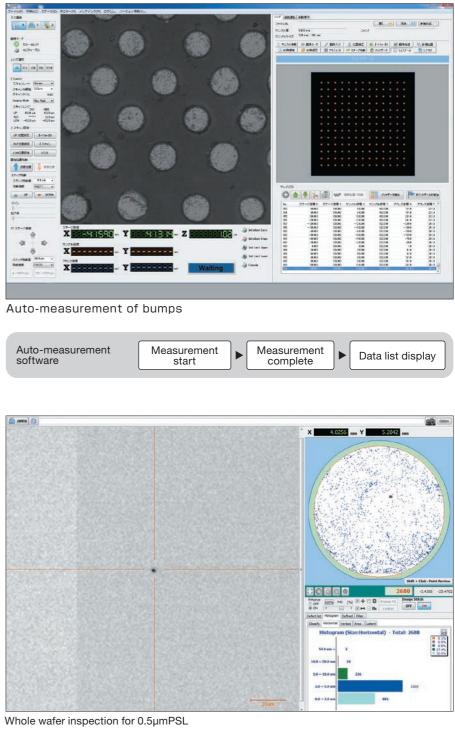
This software is used with a motorized stage to automatically perform pre-set recipes, for example, on the measurement of semiconductor pattern dimensions and surface roughness.





Auto-inspection software

This software is used to inspect a whole wafer or glass substrate for small defects and particles on surface. It also enables you to review defects in an area specified on defect-distribution map and categorize each defect (e.g., by size, white/black, pit/bump).



Auto-inspection software

Perform the expert's measurement and analysis with one click that recalls the saved commands.

Operator



White light confocal and laser confocal



Options

OPTELICS HYBRID means

Flexibility

Optional features for your specific needs

Motorized stage

The motorized stage significantly enhances the efficiency of sequential and patchwork measurements. (XY stroke 150mm x 150mm)



Electrostatic holder

This is a stage to hold a film sample with static electricity.

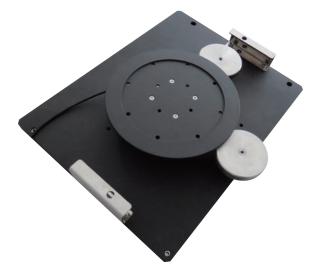


Tilt stage

This is a stage to hold a sample in a tilted position for interference measurement and roughness measurement.

Large / special stage

We can provide specially-designed stages to meet your various needs based on our inspection expertise.





S	pec	ific	atio	ons
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Model / Spec	l / Specification			Basic functions	Multifunctions	Diverse applications	
				Basic model C3	Standard model L3	High-end model L7	
				White light confocal	White light confocal	White light confocal	
					Laser confocal	Laser confocal	
						Differential interference	
						Optical interference measuremer	
						Spectroscopic reflectometry	
						film thickness measurement	
		Laser		-	405nm	405nm	
Light source		Xenon / H	g-Xe	R,G,B	R,G,B R,G,B 436nm,486nm,5 578nm,633nm		
		Objective lens	On-screen magnification		FOV (HxV)		
-		1×	18.5×		15,000×15,000μm		
		2.5×	46.2×		6,000×6,000μm		
		5×	92.5×		$3,000 \times 3,000 \mu$ m		
	White	10×	185×		$1,500 \times 1,500 \mu$ m		
FOV /	light	20×	370×		$750 \times 750 \mu$ m		
Magnification		50×	925×		$300 \times 300 \mu$ m		
		100×	1,850×		150×150 μ m		
		150×	2,775×		100×100 µ m		
-		50×	1,850×	_		150 µ m	
	Laser	100×	3,700×	_		75μm	
	Laser	150×	5,550×			50μm	
Zooming		100**	0,0001		1~8×	ουμ III	
Zooming		Brightne	222	1,024×1,024×12bit / High definition mode 2,048×2,048×12bit			
Frame memory		Height			6bit / High definition mode 2,04		
Frame rate		neigh		1,0211,0211	15Hz~120Hz		
	Minim	um unit of r	neasurement		0.001 µ m		
Width		Accura		$\pm [0.02 \times (10)]$	00/Objective lens magnification)+	-L/1000] µ m	
measurement	Re	epeatability	-	10nm			
		Scale resol			0.1nm		
		Accura			\pm (0.11+L/100) μ m		
Height measurement	R	epeatability	-	10nm			
-		Measurement range ^{%3}			7mm		
Z stroke		asur chient	lunge	100		80mm	
Nosepiece							
		Manua	1	5-hole motorized revolving nosepiece (with auto lens position recognition)			
XY stage		Motoriz		Opt		0	
 Differential ir	terferen			Opt		0	
Optical interf				Opt		0	
Spectroscopic			rement	Opt		0	
		Image cap	ture	Patchwork, HD	R mode, search peak, first peak,	multi-gain, etc.	
ľ		Basic func	tions	Measurement of height, line width and surface roughness (JIS, ISO), and 3D display			
Software		Image proce	essing	Filter, tilt correction, binarization,	, nose elimination, bit depth conversion	, size conversion, color balance, etc.	
-	Geomet	tric propert	y calculation	About 20 properties including area, volum	e, surface area, Feret diameter, center, rou	indness, maximum length, aspect ratio,	
-]	Report gene	ration	Layout, image database, template, file extension batch conversion			
Utility					AC 100-240V, 50/60Hz, 1,500VA		
		Microscope	unit	28	$(2 \text{(W)} \times 511 \text{(D)} \times 669 \text{(H)} \text{ mm} 41 \text{ kg})$		
D		Control u			$(W) \times 450 (D) \times 106 (H) mm 7.1 kg$		
Dimensions and weight		Light sourc			$2 (W) \times 311 (D) \times 227 (H) mm 6.7 kg$	•	
-		PC	c unit		$5 (W) \times 417 (D) \times 360 (H) mm 9.6 kg$		
		10		11	0 (11 / 11 / 11 / 11 / 11 / 11 / 11 / 1	,	

Based on reference pattern measurement using 150x (NA0.95) under no vibration condition.
 Based on the measurement of VLSI Standards' step height standards using 100x (NA0.95) under no vibration condition.
 Up to the maximum distance of objective lens movement

White light confocal Laser Confocal

White light confocal and laser confocal